

# PROCEEDINGS OF SPIE

## ***Nanophotonics and Micro/Nano Optics IV***

**Zhiping Zhou**  
**Kazumi Wada**  
*Editors*

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# Contents

vii	<i>Authors</i>
ix	<i>Symposium Committee</i>
xiii	<i>Conference Committee</i>

---

## SILICON PHOTONICS I

---

10823 07	<b>A novel design method of large-aperture metalens and investigation of electrical focus-tuning mechanism with phase shifter structures</b> [10823-6]
----------	--

---

## SILICON PHOTONICS II

---

10823 08	<b>Towards a fully integrated indium-phosphide membrane on silicon photonics platform (Invited Paper)</b> [10823-7]
10823 09	<b>Ultra-high efficiency III-V on Si MOS capacitor Mach-Zehnder modulator (Invited Paper)</b> [10823-8]
10823 0A	<b>Subwavelength grating devices for optical on-chip multiplexing (Invited Paper)</b> [10823-9]

---

## SILICON PHOTONICS III

---

10823 0B	<b>Reconfigurable photonic integrated devices on silicon (Invited Paper)</b> [10823-10]
10823 0D	<b>56 Gbps Si/GeSi integrated EAM (Invited Paper)</b> [10823-12]
10823 0E	<b>Two-dimensional photonic crystal bandedge resonance for perovskite laser on silicon</b> [10823-13]
10823 0F	<b>Reduction of threading dislocations by image force in Ge selective epilayers on Si</b> [10823-14]

---

## INTEGRATED OPTICS

---

10823 0H	<b>GaN photonics: simultaneous emission-detection phenomenon of multiple quantum well diode (Invited Paper)</b> [10823-16]
----------	--

10823 OJ **Analysis of bottleneck factors affecting precision manufacturing and possible solutions**  
[10823-18]

---

**NONLINEAR PHOTONICS AND QUANTUM OPTICS**

---

10823 OM **High-quality lead sulfide nanofilm deposited on silica fiber substrate by atomic layer deposition technology** [10823-21]

10823 OO **Raman spectroscopic characterization of interlayer coupling in twisted (2+2) and (3+3) layered graphenes** [10823-23]

10823 OP **Surface-related nonlinear optical enhancement in graphene and G/CdS nanohybrids**  
[10823-24]

---

**METAMATERIALS**

---

10823 OR **Design and application of photonic devices based on photonic crystal near Dirac point**  
[10823-26]

10823 OT **Dual-band total absorption via guided-mode resonance in a monolayer MoS<sub>2</sub> covered dielectric grating structure** [10823-28]

---

**NANOPHOTONICS I**

---

10823 OU **Germanium implanted photonic devices for post-fabrication trimming and programmable circuits (Invited Paper)** [10823-29]

10823 OW **Molecular self-assembly-inspired attosecond nanomedicine crystal nanobiophotonic approach: challenges and opportunities** [10823-31]

10823 OX **High-resolution laser fabrication of amplitude diffractive structures on thin metal films** [10823-32]

---

**NANOPHOTONICS II**

---

10823 OY **Upright dome nanostructure for enhanced light absorption in thin-film silicon solar cells (Invited Paper)** [10823-33]

10823 OZ **Mode engineering for circular-side square microcavity lasers (Invited Paper)** [10823-34]

10823 11 **Functional nanocellulose films as fluorescent media** [10823-36]

## POSTER SESSION

---

- 10823 12 **The inter-valley scattering between direct and indirect valleys in Ge for optimization of the germanium light** [10823-37]
- 10823 13 **Quantitative analysis of ceftazidime using SERS based on silver nanoparticles substrate** [10823-38]
- 10823 15 **Evaluation of free-radical scavenging and antioxidant activities of polydatin nanoethosomes** [10823-40]
- 10823 16 **Anti-hepatocarcinoma effects of puerarin-nanoethosomes against human HepG2 cells** [10823-41]
- 10823 17 **Enhancement of light extraction by ZnO nanostructures on vertical GaN light-emitting diodes** [10823-42]
- 10823 18 **Optical phased arrays based on silicon and GaAs photonic waveguides** [10823-43]
- 10823 1A **In-situ characterization of surface-plasmon-enhanced photocatalysis of Ag decorated black TiO<sub>2</sub> by IR-AFM** [10823-45]
- 10823 1D **Surface-plasmon-enhanced SnO<sub>2</sub> nanofiber gas sensor** [10823-48]
- 10823 1E **Label-free DNA detection based on whispering gallery mode optofluidic microcavity biosensor** [10823-49]
- 10823 1I **Polarization-dependent reflective color filter incorporating an embedded silicon grating** [10823-53]
- 10823 1J **Meta-Fresnel elements functioned by pixelated one-dimensional gratings with space-variant frequencies and orientations** [10823-54]



# Authors

Numbers in the index correspond to the last two digits of the seven-digit citation identifier (CID) article numbering system used in Proceedings of SPIE. The first five digits reflect the volume number. Base 36 numbering is employed for the last two digits and indicates the order of articles within the volume. Numbers start with 00, 01, 02, 03, 04, 05, 06, 07, 08, 09, 0A, 0B...0Z, followed by 10-1Z, 20-2Z, etc.

Abe, E., 0F  
Aihara, T., 09  
Bai, Xianhua, 0O  
Banakar, M., 0D  
Bazin, A., 0D  
Bettotti, Paolo, 11  
Chen, Bigeng, 0U  
Chen, Cai-Yun, 12  
Chen, Huacai, 13  
Chen, Linsen, 1I, 1J  
Chen, Tong-sheng, 15, 16  
Chen, Xia, 0U  
Chen, Xiaogang, 1E  
Chen, Xiao-He, 07  
Cheng, Zuguo, 0J  
Dai, Daoxin, 0B  
Domínguez Bucio, T., 0D  
Dong, Guoyan, 0R  
Dong, Yanhua, 0M  
Du, Jia-zhen, 15  
Fang, Yan, 0W  
Fu, Liang, 1E  
Fujii, T., 09  
Fukuda, H., 09  
Gao, Hongyi, 0J  
Gao, Jia-Min, 15, 16  
Gao, Jin-Bo, 07  
Gao, Jin-Song, 07  
Gao, Ruo-Qian, 07  
Gao, Yang, 18  
Gardes, F. Y., 0D  
Grabska, K. M., 0D  
Gu, Yu, 1I, 1J  
Gu, Yuzong, 0P  
Guerrero, Raphael A., 11  
Guo, Xiaowei, 0Y  
Hao, You-Zeng, 0Z  
Hasebe, K., 09  
Hattasan, N., 0D  
He, Yanling, 1A, 1D  
Hiraki, T., 09  
Hu, Jigang, 0T  
Huang, Jie, 13  
Huang, Shi-Hao, 12  
Huang, Yong-Zhen, 0Z  
Indias, Johanna Mae M., 11  
Ishikawa, Y., 0F  
Jiao, Yuqing, 08  
Kakitsuka, T., 09  
Khokhar, Ali Z., 0D, 0U  
Korolkov, Victor P., 0X  
Li, Hongju, 0T  
Li, Jiaxing, 1A, 1D  
Li, Ruxin, 0J  
Li, Shaorong, 0Y  
Li, Xiaoli, 0O  
Li, Yuanjie, 17  
Liang, Baolai, 0O  
Liao, Jiahui, 18  
Liao, Jiali, 18  
Lin, Jingyang, 1A, 1D  
Lin, Jin-Yang, 12  
Littlejohns, C., 0D  
Liu, Dajian, 0B  
Liu, Hai, 07  
Liu, Lin, 0O  
Liu, Lu, 0A  
Liu, Wei, 0T  
Liu, Zhishuang, 0E  
Lu, Hengchang, 0Y  
Lu, Qijing, 1E  
Lu, Zhengzhong, 18  
Ma, Lin, 18  
Ma, Qingyan, 0E  
Mailis, Sakellaris, 0U  
Malyshev, Anatoly I., 0X  
Mashanovich, G., 0D  
Mastronardi, L., 0D  
Matsuo, S., 09  
Meng, Xiang-Ping, 16  
Mikerin, Sergey L., 0X  
Milosevic, Milan M., 0U  
Muskens, Otto L., 0U  
Ng, Alan Man Ching, 1A, 1D  
Okotrub, Konstantin A., 0X  
Pan, Xiangping, 0M  
Peacock, Anna C., 0U  
Peng, Jiahui, 1A, 1D  
Pogoretskiy, Vadim, 08  
Qi, Haiyan, 13  
Qing, Yeming, 0T  
Qu, Hongwei, 0E  
Reed, Graham T., 0U  
Ren, Yongze, 0T  
Runge, Antoine F. J., 0U  
Rutirawut, T., 0D  
Saito, Shinichi, 0U  
Sametov, Alexander R., 0X

Scarpa, Marina, 11  
Shi, Fan, 15  
Shi, Keji, 1A, 1D  
Shi, Lili, 1A  
Shi, Yafang, 0O  
Song, Qi, 07  
Su, Caiyun, 0M  
Sun, Mingfei, 0E  
Sun, Wenci, 17  
Sun, Yanling, 18  
Takeda, K., 09  
Tang, Min, 0Z  
Tang, Yunxiang, 1D  
Thomson, David J., 0U  
Tsuchizawa, T., 09  
van der Tol, Jos J. G. M., 08  
van Engelen, Jorn P., 08  
Wada, K., 0F  
Wang, Fangfang, 0P  
Wang, Fangzhen, 0W  
Wang, Han-Cong, 12  
Wang, Hong, 17  
Wang, Longlong, 0O  
Wang, Shipeng, 0B  
Wang, Tingyun, 0M  
Wang, Xiao-Yi, 07  
Wang, Xin, 0H  
Wang, Yi-fei, 15, 16  
Wang, Yongjin, 0H  
Wang, Yufei, 0E  
Wang, Zhijie, 0E  
Wang, Zhi-ping, 15, 16  
Wang, Zihao, 18  
Wen, Jianxiang, 0M  
Weng, Hai-Zhong, 0Z  
Wu, Fan, 0H  
Wu, Shangliang, 1I, 1J  
Wu, Xiaohang, 0T  
Xiao, Jin-Long, 0Z  
Xie, Shunsen, 1E  
Xie, Weiqiang, 0T  
Xie, Wen-Ming, 12  
Xu, Zhizhan, 0J  
Yako, M., 0F  
Yang, Li, 18  
Yang, Yue-De, 0Z  
Yao, Enxu, 0T  
Ye, Hong, 1I, 1J  
Ye, Yan, 1I, 1J  
Yu, Xingshi, 0U  
Yuan, Jialei, 0H  
Yun, Feng, 17  
Zhang, Juan, 0Y  
Zhang, Minyan, 17  
Zhang, Xizheng, 0Y  
Zhao, Shuhui, 13  
Zhao, Xiaohui, 0O  
Zheng, Jiqia, 0M  
Zheng, Qi-Qiang, 12  
Zheng, Wanhua, 0E  
Zhou, Wenguang, 0O  
Zhou, Zhiping, 0A  
Zhu, Baohua, 0P

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